

CLAIMS

1. A method for producing a capacitor comprising,
as one electrode (anode), an electric conductor having
5 pores and having formed on the surface thereof a dielectric
layer and, as the other electrode (cathode), a
semiconductor layer formed on the electric conductor by
energization in an electrolytic solution, the method
comprising impregnating pores with a semiconductor layer-
10 forming precursor before energization to render the
concentration of semiconductor layer-forming precursor in
pores higher than that of semiconductor layer-forming
precursor in the electrolytic solution.

15 2. The method for producing a capacitor as claimed
in claim 1, wherein the electrolytic solution is an
electrolytic solution not containing a semiconductor layer-
forming precursor.

20 3. The method for producing a capacitor as claimed
in claim 1, wherein the electric conductor is at least one
member selected from a metal, an inorganic semiconductor,
an organic semiconductor and carbon or a mixture thereof.

25 4. The method for producing a capacitor as claimed
in claim 1, wherein the electric conductor is a laminated
body having, as the surface layer, at least one member
selected from a metal, an inorganic semiconductor, an
organic semiconductor and carbon, or a mixture thereof.

5 5. The method for producing a capacitor as claimed
in claim 3 or 4, wherein the electric conductor is a metal
or alloy mainly comprising at least one member selected
from tantalum, niobium and aluminum, or a niobium oxide.

10 6. The method for producing a capacitor as claimed
in claim 1, wherein the electric conductor is tantalum
having a CV value of 100,000 $\mu\text{F}\cdot\text{V/g}$ or more.

15 7. The method for producing a capacitor as claimed
in claim 1, wherein the electric conductor is niobium
having a CV value of 150,000 $\mu\text{F}\cdot\text{V/g}$ or more.

20 8. The method for producing a capacitor as claimed
in any one of claims 1 or 3 to 7, wherein the electric
conductor has a size of 5 mm^3 or more.

25 9. The method for producing a capacitor as claimed
in any one of claims 1 or 3 to 8 above, wherein the
electric conductor has a foil shape and the depth of pore
formed by etching is 200 μm or more.

30 10. The method for producing a capacitor as claimed
in claim 1, wherein the dielectric layer mainly comprises
at least one member selected from metal oxides such as
 Ta_2O_5 , Al_2O_3 , TiO_2 and Nb_2O_5 .

35 11. The method for producing a capacitor as claimed

in claim 1 or 2, wherein the semiconductor layer-forming precursor is at least one member selected from an aniline derivative (raw material of polyaniline), a phenol derivative (raw material of polyoxyphenylene), a thiophenol derivative (raw material of polyphenylene sulfide), a thiophene derivative (raw material of polythiophene), a furan derivative (raw material of polyfuran) and a pyrrole derivative (raw material of polypyrrole or polymethylpyrrole).

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12. The method for producing a capacitor as claimed in claim 11, wherein the semiconductor layer-forming precursor is pyrrole or 3,4-ethylenedioxythiophene.

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13. The method for producing a capacitor as claimed in claim 1 or 2, wherein the semiconductor layer-forming precursor is a compound which is oxidized or reduced by energization and becomes an inorganic semiconductor.

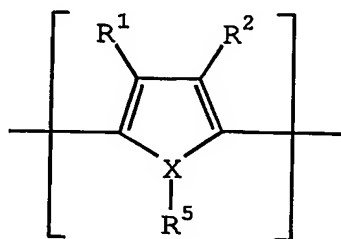
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14. The method for producing a capacitor as claimed in claim 1, wherein the semiconductor layer is at least one member selected from an organic semiconductor layer and an inorganic semiconductor layer.

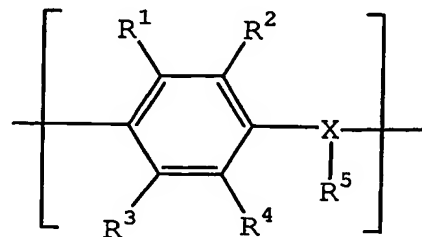
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15. The method for producing a capacitor as claimed in claim 14, wherein the organic semiconductor is at least one member selected from an organic semiconductor comprising benzopyrroline tetramer and chloranil, an organic semiconductor mainly comprising tetrathiotetracene,

an organic semiconductor mainly comprising tetracyano-quinodimethane, and an organic semiconductor mainly comprising an electrically conducting polymer obtained by doping a dopant into a polymer containing a repeating unit
 5 represented by the following formula (1) or (2):



(1)

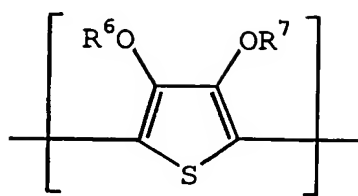


(2)

wherein R¹ to R⁴ each independently represents a hydrogen atom, an alkyl group having from 1 to 6 carbon atoms or an alkoxy group having from 1 to 6 carbon atoms, X represents
 10 an oxygen atom, a sulfur atom or a nitrogen atom, R⁵ is present only when X is a nitrogen atom, and represents a hydrogen atom or an alkyl group having from 1 to 6 carbon atoms, and each of the pairs of R¹ and R², and R³ and R⁴ may combine with each other to form a cyclic structure.

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16. The method for producing a capacitor as claimed in claim 15, wherein the electrically conducting polymer containing a repeating unit represented by formula (1) is an electrically conducting polymer containing a structure
 20 unit represented by the following formula (3) as a repeating unit:



(3)

wherein R^6 and R^7 each independently represents a hydrogen atom, a linear or branched, saturated or unsaturated alkyl group having from 1 to 6 carbon atoms, or a substituent for forming at least one 5-, 6- or 7-membered saturated hydrocarbon cyclic structure containing two oxygen atoms when the alkyl groups are combined with each other at an arbitrary position, and the cyclic structure includes a structure having a vinylene bond which may be substituted, and a phenylene structure which may be substituted.

17. The method for producing a capacitor as claimed in claim 16, wherein the electrically conducting polymer is selected from polyaniline, polyoxyphenylene, polyphenylene sulfide, polythiophene, polyfuran, pyrrole, polymethylpyrrole, and substitution derivatives and copolymers thereof.

18. The method for producing a capacitor as claimed in claim 17, wherein the electrically conducting polymer is poly(3,4-ethylenedioxythiophene).

19. The method for producing a capacitor as claimed in claim 14, wherein the inorganic semiconductor is at least one compound selected from molybdenum dioxide,

tungsten dioxide, lead dioxide and manganese dioxide.

20. The method for producing a capacitor as claimed
in any one of claims 14 to 19, wherein the electrical
5 conductivity of the semiconductor is from 10^{-2} to 10^3 S/cm.

21. A capacitor produced by the production method
claimed in any one of claims 1 to 20.

10 22. The capacitor as claimed in claim 21, wherein
the impregnation ratio of the semiconductor is 90% or more.

23. An electronic circuit using the capacitor
claimed in claim 21 or 22.

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24. An electronic device using the capacitor
claimed in claim 21 or 22.